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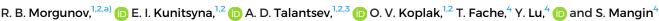
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ABSTRACT

The evolution of the switching field between stable states in MgO/CoFeB/Ta/CoFeB/MgO/GaAs and Pt/Co/Ir/Co/Pt/Ta/SiO2 synthetic ferrimagnets with perpendicular anisotropy as a function of the magnetic field sweeping rate (MFSR) of 0.1-104 Oe/s has been studied. The most significant effect of the MFSR is an inversion of the interstate transition sequence. In the MgO/CoFeB/Ta/CoFeB/MgO/GaAs heterostructure, the increase in MFSR switches the dominant mechanism of magnetization reversal from propagation of domain walls to a nucleation of reversed magnetization areas. In Pt/Co/Ir/Co/Pt/Ta/SiO2, the MFSR affects the final domain state of the transition, starting from the initial antiparallel configuration of the synthetic ferrimagnet.

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In the last ten years, magnetic relaxation of multilayered ferromagnetic heterostructures has attracted a lot of interest due to its importance in the understanding of the magnetization switching dynamics.¹⁻³ Magnetic relaxations in the MgO/CoFeB/Ta/CoFeB/ MgO/GaAs⁴ and Pt/Co/Ir/Co/Pt/Ta/Si⁵ synthetic ferrimagnets with perpendicular magnetic anisotropy (PMA) have already been studied. The time scales of these relaxations range from a few seconds to several hours. The duration of the magnetization reversal depends on the potency (expectation time) of the domain wall depinning and efficacy (kinetics) of nucleation of the reversed magnetization phase. These two mechanisms of the magnetic relaxation were combined in the Fatuzzo-Labrune model,^{6,7} describing the dynamics of magnetic relaxation in single ferromagnetic thin films, fully understood in the past few years. Magnetic relaxation contributes to the shape of the hysteresis loop as well.8 The shape of the hysteresis loop and switching fields between the parallel and antiparallel states of synthetic antiferromagnets are strongly affected by the magnetic field sweeping rate (MFSR), when the duration of the loop recording is comparable to the magnetic relaxation time. The latter depends on the lateral size of the heterostructure. If the lateral size is of a few nanometers and comparable with the thicknesses of the layers, the typical switching time \sim 1 ns is shorter by many orders of magnitude

than the duration of a hysteresis loop recording by a Kerr microscope $(\sim 1 \text{ s})$, a vibration sample magnetometer $(\sim 1 \text{ min})$, and a superconducting quantum interference device (SQUID) magnetometer (~1 h). Thus, the values of magnetization reversal parameters in nanosized heterostructures as nanopillars and nanodots are independent of the measurement technique used. In contrast, heterostructures of a large lateral size (5 mm × 5 mm or larger) manifest long-lasting magnetic relaxation dynamics ($\sim 10^3 - 10^4$ s), limited by the domain propagation time throughout the sample area, 9,10 and the duration of magnetization reversal can become comparable to the magnetic hysteresis loop recording time. In that case, the observed value of the interstate transition field is expected to be strongly dependent on MFSR.

In general, synthetic antiferromagnets with two ferromagnetic layers of different thicknesses show four stable states, P⁺, AP⁺, AP⁻, and P [Fig. 1(a)], corresponding to parallel and antiparallel mutual orientations of magnetizations in top and bottom layers (P and AP, respectively) and the positive or negative sign of the net magnetic moment value (indicated by a "+" or "-" sign). The magnetic field range, at which the interstate transition occurs, is dependent on the balance between the energy terms of the synthetic antiferromagnet under an applied magnetic field: magnetic energy of the layers,

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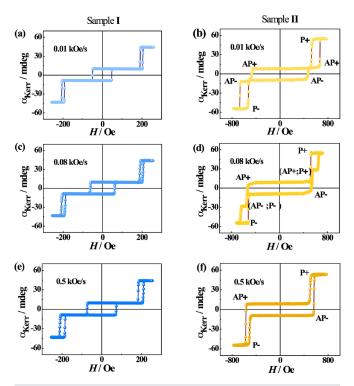


FIG. 1. MOKE hysteresis loops of sample I [(a), (c), and (e)] and sample II [(b), (d), and (f)], recorded at $T=300\,\mathrm{K}$ at 0.01 kOe/s, 0.08 kOe/s, and 0.5 kOe/s magnetic field sweep rates.

anisotropy energies, domain unpinning barriers, and interlayer RKKY coupling. In this work, the thicknesses of the Co ferromagnetic layers and the Ir spacer layer in the Pt/Co/Ir/Co/Pt/Ta/SiO₂ structure were selected in a way that the AP⁺ to AP⁻ transition (synchronous reversals of the top and bottom Co layers) and the AP⁺ to P-transition (reversal of the bottom Co layer only) proceed in overlapping field ranges. The MgO/CoFeB/Ta/CoFeB/MgO/GaAs structure was selected as a reference sample, where the transition fields do not overlap. This work is aimed at the experimental analysis of the MSFR effect on transition fields and the transition sequence for the "overlapping" case and comparison of this effect with the conventional one in synthetic antiferromagnets without an overlap of transition fields.

The MgO (2.5 nm)/CoFeB (1.1 nm)/Ta (0.75 nm)/CoFeB (0.8 nm)/ MgO (2.5 nm)/Ta (5 nm) [Fig. S1(a)] double ferromagnetic layer system was deposited on the undoped GaAs (001) substrate by magnetron sputtering. The Energy Dispersive X-Ray Spectroscopy (EDX) chemical analysis of the layers and TEM images of the cross section of this heterostructure are presented in Ref. 11. Continuous and homogeneous $3 \times 3 \, \text{mm}^2$ plate-shaped layer structures with perpendicular anisotropy were identified.

The multilayered structure Pt $(3 \text{ nm})/\text{Co} (1.0 \text{ nm})/\text{Ir} (1.5 \text{ nm})/\text{Co} (1.5 \text{ nm})/\text{Pt} (3 \text{ nm})/\text{Ta} (3 \text{ nm})/\text{SiO}_2$ [Fig. S1(b)] was prepared by deposition on the undoped Si/SiO₂ substrate of size $0.4 \times 4 \times 5 \text{ mm}^3$ by magnetron sputtering in 10^{-8} Torr vacuum. The iridium spacer allows one to predict the oscillating RKKY exchange interaction as a function of its thickness. ¹²

The recording of dynamic hysteresis loops and domain observation at room temperature (300 K) were performed using a Durham Magneto-optics NanoMOKE3 Magneto Optical Kerr Effect (MOKE) measurement system, in the polar MOKE measurement configuration. The domain imaging was performed at a 2 Oe/s field sweep rate with an image scanning time of 0.5 s per frame, which was $10^2 - 10^4$ times less than the time of domain wall propagation through the microscope observation area.

Microwave nonresonant absorption was recorded using a Bruker ESP 300 X-band ESR spectrometer (microwave frequency was $f_0=9.447\,\mathrm{GHz}$, microwave power 6.3 mW, modulation frequency 100 kHz, modulation amplitude 10 Oe, and quality factor Q ~ 4000). If the resistance of the sample is lower than the resistance of the microwave circuit ($R_{\rm C}\sim 190\,\Omega$), absorbed microwave power P is proportional to sample resistance ρ and depends on magnetic field $P\sim \rho(H)$. $^{13-15}$ Thus, in our experiments, the derivation of absorbed microwave power measured by the modulation method was directly proportional to the derivation of specific resistance ρ of the sample $dP/dH\sim d(\rho(H))/dH$. Magnetic hysteresis loops were recorded using an MPMS 5XL Quantum Design superconducting quantum interference device (SQUID) magnetometer. The sweeping rate in this method was the slowest in comparison with the two methods mentioned above.

The magnetic hysteresis loops recorded by the MOKE technique at three different MFSR values in the CoFeB bilayer (sample I) at 300 K are presented in Figs. 1(a), 1(c), and 1(e). Parallel and antiparallel alignments of the magnetizations of the bottom layer (0.8 nm thickness) and top layer (1.1 nm) thickness result in four stable magnetic states P⁺, P⁻, AP+, and AP-. Transitions between the stable states result in three minor hysteresis loops: the central one and the two side ones, shifted from zero field by ~200 Oe due to the negative exchange coupling between both CoFeB layers. ¹⁶ The transition from the AP⁺ to AP⁻ state starts by nucleation of AP- domains and their growth by propagation of AP⁺/AP⁻ domain walls. A series of the microimages of one of the magnetic nuclei at MFSR = 2 Oe/s are presented in Fig. 2(a). The switching fields of the central (Fig. S2) and side (Fig. S3) hysteresis loops depend on the MFSR during loop recording. With an increase in the MFSR from 0.1 Oe/s (typical for the SQUID magnetometer) to 10 kOe/s (typical for the MOKE technique), the $AP^+ \rightarrow AP^-$ transition field grows 3 times, from 20 Oe to 60 Oe [Fig. 3(a)]. This growth of the switching field with MSFR can be described in terms of energy balance for the synthetic antiferromagnet.

In a single thin film, the dependence of the switching critical field, $H_{\rm C}$, on the MFSR value dH/dt typically follows the logarithmic law:^{17,18}

$$H_C(R) = H_f \ln(R) + \text{const}, \tag{1}$$

where H_f is the fluctuation field and R = dH/dt is MFSR.

To extend this equation for synthetic antiferromagnets, the interlayer coupling energy, magnetic energies of two layers, and anisotropy energies should be taken into account.

For $AP^+ \rightarrow AP^-$ transition,

$$H_C = H_f \ln\left(\frac{R}{R_0}\right) + \frac{K_A}{2M_S} \frac{h_2 + h_1}{h_2 - h_1},$$
 (2)

$$H_f = \frac{kT}{2M_S V_A} \frac{h_2 + h_1}{h_2 - h_1},\tag{3}$$

$$R_0 = \frac{f_0 kT}{M_S V_A} \frac{h_2 + h_1}{h_2 - h_1},\tag{4}$$

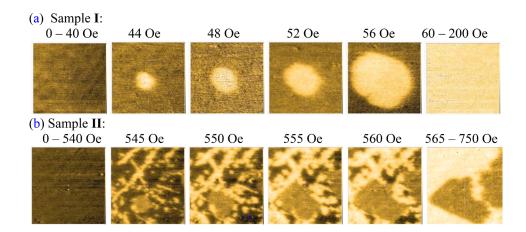


FIG. 2. MOKE images of domains, corresponding to the $AP^+ \rightarrow AP^-$ transition field range, in sample I (MgO/CoFeB/Ta/CoFeB/MgO) (a) and sample II (Pt/Co/Ta/Co/Pt) (b), recorded at $T=300~{\rm K}$ at a 2 Oe/s magnetic field sweep rate.

where $K_{\rm A}$ is the anisotropy constant, $V_{\rm A}$ is the activation volume, $M_{\rm S}$ is the saturation magnetization ($K_{\rm A}$ and $M_{\rm S}$ values were supposed to be similar for top and bottom layers of synthetic antiferromagnet), h_1 and h_2 are the thicknesses of top and bottom layers, respectively, and f_0 is the attempt frequency (Arrhenius factor) of domain nucleation. The interlayer coupling energy is not present in Eqs. (2)–(4), as the ${\rm AP}^+ \to {\rm AP}^-$ transition proceeds between two antiparallel states and, therefore, does not change the sign of interlayer coupling. However, the switching field depends on interlayer coupling energy

for $P^+ \to AP^+$ and $AP^- \to P^-$ transitions, when the mutual orientation of magnetizations in top and bottom layers changes from collinear to opposite and vice versa (See Appendix I in the supplementary material).

The derivation of these equations and the formulas for other transitions in the synthetic antiferromagnet are given in Appendix I supplementary material. Equation (3) for a fluctuation field in a bilayer system is similar to the one for single layer thin films, ¹⁹

$$H_{\rm f} = kT/(2V_{\rm A}M_{\rm S}),\tag{5}$$

with an exception of the $(h_2 + h_1)/(h_2 - h_1)$ term. The physical meaning of this term is that for the same temperature and activation volume, the fluctuation field in a bilayer is much larger than that in a single layer thin film. The H_f value depends on the mechanism of the domain wall pinning and is sensitive to the "strong" or "weak" pinning cases. 20,21 Thus, the $H_{\rm f}$ parameter characterizes the thermal stability of the material, being dependent on the ratio between the energy of the reversal magnetization phase nucleation and the energy of the domain wall pinning by structural defects. Since the thicknesses of the magnetic layers in our samples (0.8 nm and 1.1 nm) are of a few lattice parameters (0.4 nm), any defect of crystalline structure corresponds to a local change of the film thickness by 20%-30%. For that reason, the fluctuation field H_c is comparable to the coercive field H_c (Table 1 in the supplementary material) and can be changed by few times in contrast to the bulk sample or thick (>10 nm) films, where the change of the MFSR by few orders of value causes a change in H_f by few percent. Thus, in the thin films, the results of measurements of the fluctuation field strongly depend on the method of measurement [in SQUID MFSR = 0.1 Oe/s, in Ferromagnetic resonance (FMR) MFSR = 0.2-20 Oe/s (Fig. S4), and in MOKE microscope MFSR = 10 kOe/s].

The $H_{\rm C}(\ln R)$ dependence has a kink at $R \sim 500$ Oe/s [Fig. 3(a)]. This kink cannot be explained by the change of the sign of the derivative of domain wall velocity in the magnetic field close to the Walker limit. A more realistic explanation of the kink can be proposed on the basis of consideration of the competition between two ways of transitions from the AP⁺ to AP⁻ state: by nucleation of the magnetization reversal phase and propagation of the domain walls. In this mode, the number of nuclei becomes dependent on the external magnetic field before full magnetization reversal of the film is realized by the growth of nuclei. Thus, the activation volume and fluctuation field

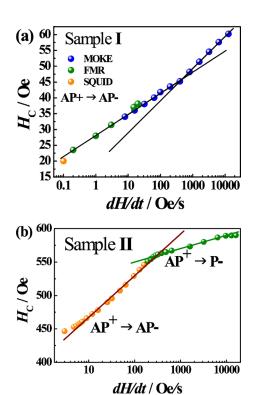


FIG. 3. The dependence of the transition field on the magnetic field sweep rate (semilogarithmic scale), for sample I (MgO/CoFeB/Ta/CoFeB/MgO) (a) and sample II (Pt/Co/lr/Co/Pt) (b). Solid lines are linear approximations.

in high MFSR modes are controlled by both the nucleation field and the depinning field (see Fig. S5 in the supplementary material).

An evolution of the magnetic hysteresis loop with MFSR for the Pt/Co/Ir/Co/Pt/Ta/SiO₂ structure (sample II) is presented in Figs. 1(b), 1(d), and 1(f). In addition to the shift of transition fields, an increase in MFSR results in the inversion of interstate transition sequence. At slow field sweep rates (below 0.01 kOe/s), the switching from the AP⁺ state to the P state proceeds via the AP state as two separate transitions: (i) $AP^+ \rightarrow AP^-$ – synchronous propagation of the AP^+/AP^- domain wall in top and bottom Co layers in the 470-520 Oe field range and (ii) $AP^- \rightarrow P^-$ - nucleation of domains in the top Co layer, in the 720-750 Oe field range. With an increase in MFSR, it is expected that the $AP^+ \rightarrow AP^-$ transition field will increase, until it reaches the $AP^ \rightarrow$ P⁻ transition field (\sim 750 Oe) and the AP⁻ state is no more dwelled. However, a different process is experimentally observed. The AP+ \rightarrow AP⁻ transition field does not reach the AP⁻ \rightarrow P⁻ transition field. Instead, at \sim 550 Oe, a domain nucleation in the bottom layer, resulting in the direct transition from the AP+ to P- state, starts to proceed together with the $AP^+ \rightarrow AP^-$ one. When the MFSR is in a range of 0.02 kOe/s-0.45 kOe/s, these two processes occur together and competitively, leading to a multidomain stable magnetic state (AP-; P-), lying in between AP⁻ and P⁻ [Fig. 1(d)].

A series of MOKE images recorded in intermediate MFSR is shown in Fig. 2(b). Three types of areas can be distinguished in these images: Dark areas correspond to the AP⁺ state, the areas of the intermediate brightness correspond to the AP⁻ state, and light areas correspond to the P⁻ state. When this transition is completed [Fig. 2(b), last image], domains of two states AP⁻ and P⁻ coexist and this (AP⁻; P⁻) state is stable in the 550 Oe-750 Oe field range. The proportion between the areas, occupied by AP⁻ and P⁻ domains, was found to be dependent on MFSR (Fig. S6, supplementary material). When the field reaches 750 Oe, those areas, which are in the AP⁻ state, switch to the P⁻ state, until all the areas of the film are switched to the P⁻ state.

At high MFSR values (>0.5 kOe/s), the transition in 750 Oe disappears [Fig. 1(f)] and the reversal from the AP+ to P- state becomes fully completed at a lower magnetic field, ~600 Oe, corresponding to the nucleation of magnetic domains in the bottom Co layer. It means that at high MFSR, the reversal from AP+ to P- is localized in the bottom Co layer only. No formation of domain nuclei in the top Co layer occurs at high MFSR. In contrast, at low MFSR values, due to the AP+ to AP preceding process, the domain nucleation occurs in the top Co layer and does not happen in the bottom Co layer. Thus, an increase in MFSR results in relocalization of the domain nucleation process from the top to the bottom Co layer, by suppression of propagation of AP⁺/AP⁻ domain walls. The evidence of this relocalization are (i) the appearance of the direct $AP^+ \rightarrow P^-$ process, corresponding to domain nucleation in the bottom Co layer, at intermediate MFSR, and (ii) the disappearance of transition at 750 Oe, corresponding to domain nucleation in the top Co layer, at high MFSR.

Dynamics of the AP^- and P^- domain nucleation and propagation is summarized in Fig. S5(b) of the supplementary material for three ranges of the MFSR: Slow mode ($<0.01\,kOe/s$), intermediate mode ($0.02\,kOe/s-0.45\,kOe/s$), and fast mode ($>0.5\,kOe/s$). For the transitions, starting from the AP^+ state, the dependences of switching fields on MFSR are presented in Fig. 3(b). The fluctuation field and the activation volume, extracted by linear approximations of the straight parts of these dependences by formula (1), are presented in Table 1 of

the supplementary material. These values are close to the ones obtained in SmCo₅/Fe/SmCo₅ trilayers³ and Co/Pt multilayer structures.²⁴ The $H_C(dH/dt)$ dependences abruptly change the slope at the critical dH/dt value in the CoFeB sample, as well as in the Pt/Co sample. However, the origins of these features are different in Pt/Co and CoFeB synthetic ferrimagnets. In the CoFeB based heterostructures, the slope increases due to the progressive involvement of the domain nucleation process with the increase in MFSR. In contrast to CoFeB synthetic ferrimagnets, in the Pt/Co samples, the slope of $H_C(dH/dt)$ decreases, and it is caused by migration of the final magnetization state. At low MFSR values, the $AP^+ \rightarrow AP^-$ transition takes place, while at high MFSR values, the $AP^+ \rightarrow P^-$ transition occurs. Different slopes of the dependence of switching field $H_{\rm C}$ on the sweeping rate R= dH/dt in logarithmic coordinates $[H_C; ln(R)]$ [Fig. 3(b)] indicate the difference between the fluctuation fields and activation volumes corresponding to the $AP^+ \rightarrow AP^-$ and $AP^+ \rightarrow P^-$ transitions most probably due to different heights of the activation barriers of these transitions. The $AP^+ \rightarrow P^-$ transition corresponds to the magnetization reversal of just one of the ferromagnetic layers. Thus, the realization of the $AP^+ \rightarrow P^-$ transition requires overcoming the barrier E_1 corresponding to the single layer, while the $AP^+ \rightarrow AP^-$ transition corresponds to the magnetization reversal of both the layers requiring to overcome the sum of the activation energies $E_1 + E_2$ of both the ferromagnetic layers.

In multilayered synthetic ferrimagnets Pt/Co/Ir/Co/Pt and CoFeB/Ta/CoFeB with perpendicular anisotropy, the magnetic field sweeping rate dependence of the switching field between different stable states has been investigated. The increase in the sweeping rate on 5 orders of magnitude from 0.1 Oe/s up to 10 kOe/s changes the AP $^+$ \rightarrow AP $^-$ switching field in CoFeB/Ta/CoFeB by a factor of 3 (from 20 Oe to 60 Oe). More interestingly, in a Pt/Co/Ir/Co/Pt heterostructure, the sequence of the transitions between stable states can be changed by controlling the sweeping rate of the magnetic field.

Two mechanisms could be proposed to explain those behaviors. In CoFeB/Ta/CoFeB by modifying the sweeping rate, the magnetization reversal changes from domain wall propagation to nucleation, dominating at a high sweeping rate. In the Pt/Co/Ir/Co/Pt structure, an increase in the magnetic sweeping rate changes the type of switching from $AP^+ \to AP^-$ and $AP^- \to P^-$ transitions. Simultaneous contributions of the $AP^+ \to AP^-$ and $AP^+ \to P^-$ transitions to magnetization reversal result in a stable multidomain state of the heterostructure, with coexisting domains of AP^- and P^- states.

An increase in MFSR results in the relocalization of the domain nucleation process from the top to the bottom Co layer, by suppression of the propagation of $\mathrm{AP}^+/\mathrm{AP}^-$ domain walls. The evidences of this relocalization are (i) the appearance of a direct $\mathrm{AP}^+\to\mathrm{P}^-$ process, corresponding to domain nucleation in the bottom Co layer, at intermediate MFSR, and (ii) the disappearance of transition at 750 Oe, corresponding to domains nucleation in the top Co layer, at high MFSR.

See the supplementary material for the structure of two samples, complete ESR and MOKE data of the samples, a sketch of the nucleation for different MFSR, and activation volumes of the transitions.

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